	Application No.	Applicant(s)
Notice of Allowability		
	10/715,903 Examiner	ANDERSSON ET AL.
	Examiner	Art Unit
	Henry S. Hu	1713
The MAILING DATE of this communication apper All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this or other appropriate communicat GHTS. This application is subject	application. If not included ion will be mailed in due course. <b>THIS</b>
1. This communication is responsive to <u>RCE/IDS of June 4, 2007</u> .		
2. The allowed claim(s) is/are <u>1-21,28,40,41 and 43</u> .		
3. Acknowledgment is made of a claim for foreign priority un a) All b) Some* c) None of the:		
1. Certified copies of the priority documents have been received.		
2. Certified copies of the priority documents have been received in Application No		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
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Attachment(s) 1. ☑ Notice of References Cited (PTO-892)	5 Motion of Informa	I Potent Application
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	<ul><li>5. ☐ Notice of Informa</li><li>6. ☐ Interview Summa</li></ul>	• •
2. Mouce of Diarperson's Faterit Diawing Neview (F10-940)	Paper No./Mail [	Date
<ol> <li>Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date 6-4-2007</li> </ol>	7.   Examiner's Amer	ndment/Comment
Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. ⊠ Examiner's State	ment of Reasons for Allowance
C. Diological Material	9.	

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## **DETAILED ACTION**

1. Applicants' RCE and newly submitted IDS filed on June 4, 2007 were both received.

The examiner has closely considered all the <u>twelve</u> US patent references as specified in the IDS.

Claims 1-21, 28, 40-41 and 43 with <u>two</u> independent claims (Claims 1 and 28) are now pending. An action follows.

## Allowable Subject Matter

- 2. Claims 1-21, 28, 40-41 and 43 are allowed.
- 3. The following is an examiner's statement of reasons for allowance: The above claims 1-21, 28, 40-41 and 43 are allowed over the closest references:
- 4. The limitation of parent Claim 1 in present invention relates to <u>an antimicrobial</u>

  ophthalmic lens comprising a metal salt and having a percent <u>haze</u> of less than 200% and exhibiting, in the presence of viable bacteria or other microbes, <u>a reduction</u> of said viable bacteria or other microbes of <u>at least about 0.5 log</u>.

Other parent Claim 28 relates to <u>two-stepwise method</u> of producing an antimicrobial ophthalmic lens comprising a metal salt, wherein said lens exhibits, in the presence of viable

bacteria or other microbes, <u>a reduction</u> of said viable bacteria or other microbes of <u>at least</u> about 0.5 log.

See other limitations of dependent Claims 2-21, 40-41 and 43.

5. The previous Notice of Allowance filed on March 2, 2007 is now incorporated here by reference. In a close examination on the prior art as mentioned on the newly submitted IDS filed on June 4, 2007 along with a further examination and search, the examiner has found the following prior art did not teach the claimed limitation: Applicants have claimed now in each of two parent claims including Claim 1 (composition) and Claim 28 (process of making) an unexpected way of obtaining an antimicrobial ophthalmic lens exhibiting an advantage as, in the presence of viable bacteria or other microbes, a reduction of said viable bacteria or other microbes of at least about 0.5 log. The key point is that the lens comprises a metal salt and having a percent haze at less than 200%. It is noted parent Claim 28 is the process of making the same composition of Claim 1.

Based on the fact that each of parent Claims 1 and 28 in this IDS/RCE carries exact the same scope as the one allowed on March 2, 2007. Same rationale for allowance is thereby applied here accordingly.

6. In a very close examination on pending 102 and/or 103 rejections, all involving references including **Rathore**, **Borowsky**, **Barry and McCabe**, alone or in combination, cannot stand now with current claim limitation as follows:

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In view of the <u>first Declaration</u> written by Inventors Rathore and Anderson as well as the statement on page <u>10</u> at top section of Remarks, USPG-PUB 2004/0151755 A1 Rathore et al. with effective US filing date of December 21, 2000 and the same assignee thereby cannot be used as a prior art for 102(e) rejection according to MPEP.

- 7. In view of the <u>second Declaration</u> written by Inventors Vanderlaan as well as different results being obtained by repeating US 4,576,453 to Borowsky 's procedure, such obtained lens from Borowsky indeed does not show a reduction of viable bacteria more than 0.5 log.

  Although Borowsky or Barry may disclose the preparation of contact lens by adding some metal ion such as silver salt (AgX) or silver zeolite in the form as a solution into a hydrogel lens so that metal ion can be stayed within gel matrix and such a contact lens having silver ion may be for antimicrobial purpose. However, each reference is still silent of two things as: (A) the lens property having the percent haze at less than about 200%, and (B) a reduction of viable bacteria more than 0.5 log.
- 8. As pointed out by Applicants on pages 11 and 12 of Remarks, Barry provides no motivation to replace zeolites with the claimed metal salt, while McCabe does not disclose or suggest incorporating metal salts into a contact lens.

After further search, it is noted that <u>no search report</u> is found for Applicants' PCT/US2003/037409 (<u>WO 2004/047879 A2</u>) and the priority paper EP 1,754,494 A2.

percent haze at less than 200%.

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9. After examining twelve US patents cited in new IDS, they do disclose the preparation of some silver salt-containing antimicrobial products. The salt can be silver chloride, silver nitrate, silver perchlorate and the like. Only US 2005/0013842 A1 (can not be used as prior art reference since it carries a US effective filing date of July 16, 2003) mentions the issue of haze (see paragraph 0287). In a very close examination, the key issue is not disclosed or suggested by remaining eleven cited references. The key issue is on making an metal salt-containing antimicrobial ophthalmic lens so as to carry two properties as: (A) exhibiting a reduction of said viable bacteria or other microbes of at least about 0.5 log, and (B) the lens has a

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- 10. Additionally, the present invention has shown in examples along with some comparative examples for making such an antimicrobial ophthalmic lens (see pages 23-51 for examples 1-33 (with control) along with its **Tables 1-8**). Therefore, all the above-mentioned references, in combination or alone, does not teach or fairly suggest the limitations of present invention. In summary, the above references (which are mentioned before) and new <u>twelve</u> IDS references, in combination or alone, fails to teach or fairly suggest the limitations of present invention.
- 11. After further examination and search, the examiner found the following prior art did not teach the claimed limitation: US 5,520,910 to Hashimoto et al. (or its equivalent WO 95/02617 to Hashimoto et al.) only discloses an antimicrobial contact lens can be made from (A) a polymer obtained by homo- or copolymerizing a phosphonium salt type vinyl

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monomer, and (B) a large quantity of an antimicrobial agent or a potent antimicrobial agent (abstract, line 1-7; column 2, line 35-37). However, metal salt is not disclosed or suggested. The claimed percent haze and the claimed reduction of viable bacteria or other microbes are both not disclosed at all. Therefore, Hashimoto fails to teach or fairly suggest the copolymers of present invention.

US 6,815,074 B2 to Aguado et al. only discloses an ophthalmic antimicrobial contact lens useful for extended-wear periods can be made from (A) a polymer obtained by polymerization of aoxyperm macromer and an ionoperm monomer (abstract, line 1-10; column 2, line 35-37). Although lens haze is discussed (column 20, line 22-62), metal salt is not disclosed or suggested adding into the lens composition. The claimed percent haze and the claimed reduction of viable bacteria or other microbes are both not disclosed at all. Therefore, Aguado fails to teach or fairly suggest the copolymers of present invention.

- 12. The key issue on making an metal salt-containing antimicrobial ophthalmic lens so as to carry two properties as: (A) exhibiting a reduction of said viable bacteria or other microbes of at least about 0.5 log, and (B) the lens has a percent haze at less than 200%, cannot be overcome by any or the combination of the above references, therefore, the present invention is novel.
- 13. As of the date of this office action, the examiner has not located or identified any reference that can be used singularly or in combination with another reference including the above references to render the present invention anticipated or obvious to one of the ordinary

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skill in the art. Therefore, the two independent and parent Claims 1 and 28 are allowed for the

reason listed above. Since the prior art of record fails to teach the present invention, the

remaining pending dependent Claims 2-21, 40-41 and 43 are passed to issue.

14. Any inquiry concerning this communication or earlier communication from the examiner

should be directed to Dr. Henry S. Hu whose telephone number is (571) 272-1103. The

examiner can be reached on Monday through Friday from 9:00 AM -5:00 PM. If attempts to

reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Wu, can be

reached on (571) 272-1114. The fax number for the organization where this application or

proceeding is assigned is (571) 273-8300 for all regular communications. Information

regarding the status of an application may be obtained from the Patent Application Information

Retrieval (PAIR) system. Status information for published applications may be obtained from

either Private PAIR or Public PAIR. Status information for unpublished applications is available

through Private PAIR only. For more information about the PAIR system, see <a href="http://pair-rough">http://pair-rough</a> Private PAIR only.

direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the

Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Henry S. Hu

Patent Examiner, Art Unit 1713, USPTO

June 10, 2007

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